## **AMENDMENTS TO THE CLAIMS**

This listing of claims will replace all prior versions, and listings, of claims in the application.

## **LISTING OF CLAIMS:**

- 1-21. (canceled).
- 22. (new) An n-channel or ambipolar field-effect transistor including an organic semiconductive layer having an electron affinity EA<sub>semicond</sub>; and an organic gate dielectric layer forming an interface with the semiconductive layer; characterised in that the bulk concentration of trapping groups in the gate dielectric layer is less than 10<sup>18</sup>cm<sup>-3</sup>, where a trapping group is a group having (i) an electron affinity EA<sub>x</sub> greater than or equal to EA<sub>semicond</sub> and/or (ii) a reactive electron affinity EA<sub>rxn</sub> greater than or equal to (EA<sub>semicond</sub>-2eV).
- 23. (new) A transistor according to claim 22, wherein the transistor is an ambipolar field-effect transistor.
- 24. (new) A transistor according to claim 22 wherein EA<sub>semicond</sub> is greater than or equal to 2eV.
- 25. (new) A transistor according to claim 24 wherein EA<sub>semicond.</sub> is in the range of from 2eV to 4eV.
- 26. (new) A transistor according to claim 22 wherein the gate dielectric layer comprises an organic insulating material and the organic insulating material does not contain a repeat unit or residue unit comprising a trapping group.
- 27. (new) A transistor according to claim 22, wherein the insulating material does not contain a repeat unit or residue unit comprising a group having (i) an electron affinity EA<sub>x</sub>

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greater than or equal to 3eV and/or (ii) a reactive electron affinity  $EA_{rxn}$  greater than or equal to 0.5eV.

- 28. (new) A transistor according to claim 27 wherein the insulating material does not contain a repeat unit or residue unit comprising a quinone, aromatic –OH, aliphatic –COOH, aromatic –SH, or aromatic -COOH group.
- 29. (new) A transistor according to claim 22, wherein the insulating material contains one or more groups selected from alkene, alkylene, cycloalkene, cycloalkylene, siloxane, ether oxygen, alkyl, cycloalkyl, phenyl, and phenylene groups.
- 30. (new) A transistor according to claim 22 wherein the insulating material comprises an insulating polymer.
- 31. (new) A transistor according to claim 30, wherein the insulating polymer is selected from the group consisting of substituted and unsubstituted poly(siloxanes) and copolymers thereof; substituted and unsubstituted poly(alkenes) and copolymers thereof; substituted and unsubstituted poly(styrenes) and copolymers thereof; and substituted and unsubstituted poly(oxyalkylenes) and copolymers thereof.
- 32. (new) A transistor according to claim 31, wherein the backbone of the insulating polymer comprises a repeat unit comprising  $-Si(R)_2$ -O-Si(R)<sub>2</sub>- where each R independently is methyl or substituted or unsubstituted phenyl.
- 33. (new) A transistor according to claim 30, wherein the insulating polymer is crosslinked.
- 34. (new) A transistor according to claim 22 wherein the organic semiconductive layer comprises a semiconductive polymer.

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- 35. (new) A transistor according to claim 22 wherein the organic semiconductive layer comprises a semiconductive oligomer.
- 36. (new) A transistor according to claim 22 wherein the organic semiconductive layer comprises a semiconductive small molecule.
- 37. (new) A method for making a transistor as defined in claim 22.
- 38. (new) Use of a transistor according to claim 22 for n-channel conduction in an n-channel or ambipolar field effect transistor.
- 39. (new) Use of an organic gate insulating material that does not contain any chemical groups having (i)EA<sub>X</sub> greater than or equal to 3eV and/or (ii)EA<sub>rxn</sub> greater than or equal to 0.5eV, for n-channel conduction.
- 40. (new) Use according to claim 39, wherein the insulating material does not contain any chemical groups having (i) $EA_X$  greater than or equal to 2eV and/or ( $EA_{rxn}$ ) greater than or equal to 0eV.
- 41. (new) A circuit, complementary circuit, or logic circuit including a transistor as defined in claim 22.
- 42. (new) A method for making a circuit, complementary circuit, or logic circuit as defined in claim 41.